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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/815,788	04/02/2004	Dong-Gyu Kim	6192.0368.US	9930
23345	7590 05/05/200		EXAMINER	
MCGUIREWOODS, LLP 1750 TYSONS BLVD			LOUIE, WAI SING	
SUITE 1800			ART UNIT	PAPER NUMBER
MCLEAN, VA 22102			2814	
			DATE MAILED: 05/05/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application N	o. Applio	cant(s)			
Office Astion Comme	10/815,788	KIM De	ONG-GYU			
Office Action Summary	Examiner	Art Un	nit			
	Wai-Sing Loui					
The MAILING DATE of this commu Period for Reply	nication appears on the co	ver sheet with the correspo	ondence address			
A SHORTENED STATUTORY PERIOD THE MAILING DATE OF THIS COMMUN  - Extensions of time may be available under the provision after SIX (6) MONTHS from the mailing date of this conc. If the period for reply specified above is less than thirty. If NO period for reply is specified above, the maximum. Failure to reply within the set or extended period for reply reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In no event, h munication. (30) days, a reply within the statutory statutory period will apply and will exp ly will, by statute, cause the application	owever, may a reply be timely filed minimum of thirty (30) days will be co ire SIX (6) MONTHS from the mailing on to become ABANDONED (35 U.S	onsidered timely. g date of this communication. C. § 133).			
Status						
1) Responsive to communication(s) fi	led on					
2a) ☐ This action is FINAL.	·					
•—	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4) ⊠ Claim(s) <u>1-23</u> is/are pending in the 4a) Of the above claim(s) is/s 5) □ Claim(s) is/are allowed. 6) □ Claim(s) is/are rejected. 7) □ Claim(s) is/are objected to. 8) ⊠ Claim(s) <u>1-23</u> are subject to restrict	are withdrawn from consid					
Application Papers						
9) The specification is objected to by the specification is objected to by the specific sp	e: a) accepted or b) control accepted or b) control accepted or b) control accepted by acc	eld in abeyance. See 37 CF	R 1.85(a).			
11) The oath or declaration is objected						
Priority under 35 U.S.C. § 119						
<ul> <li>12)  Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a)  All b)  Some * c) None of: <ol> <li>Certified copies of the priority documents have been received.</li> <li>Certified copies of the priority documents have been received in Application No</li> <li>Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review  3) Information Disclosure Statement(s) (PTO-1449 Paper No(s)/Mail Date	or PTO/SB/08) 5)	Interview Summary (PTO-41 Paper No(s)/Mail Date.  Notice of Informal Patent Ap Other:	<u> </u>			

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## **DETAILED ACTION**

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

Claims 1-20, drawn to a thin film transistor array, classified in class 257, subclass
 213.

II. Claims 21-23, drawn to a method of manufacturing the device, classified in class438, subclass 75.

The inventions are distinct, each from the other because of the following reasons:

Inventions Group I and Group II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, the product as claimed can be made by another and materially different process, such that instead of forming the gate line and then forming a semiconductor layer, it would be possible to form the semiconductor layer first and then form the gate line on top.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

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Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wai-Sing Louie whose telephone number is (571) 272-1709. The examiner can normally be reached on 7:30 AM to 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Wsl \_\_\_\_\_\_. May 2, 2005.